## NANOSCALE RESEARCH FACILITY (NRF) INDIAN INSTITUTE OF TECHNOLOGY DELHI HAUZ KHAS, NEW DELHI- 110016

Date: May 12, 2011

## NOTICE INVITING QUOTATIONS

Ref: No. NRF/AFM/2011

## Due date: June 3, 2011

Please send your quotations to the undersigned in a sealed cover super scribed with our Ref no. & due date for the following items (atomic force microscopy with multiple options).

S.No.	Name of item with full specifications	quantity	
1	Scanning Probe Microscopy system	1	
	A. Operating modes:		
	<ul> <li>i. Tip/sample scanning configuration</li> <li>ii. Contact, Non-contact, AC (intermittent contact), Constant force, Constant height, phase, amplitude and force modulation imaging, Lateral Force</li> <li>iii. Scanning tunnelling microscopy (STM), scanning magnetic force microscopy(MFM), Electric Force microscopy (EFM), Surface potential (Scanning Kelvin Probe Microscopy), Piezo Force Microscopy (PFM), Conductive AFM imaging, scanning thermal microscopy (STM) and all other standard imaging options.</li> </ul>		
	<b>B.</b> Other non-imaging modes: Current-voltage (I/V) spectroscopy, Force-distance spectroscopy, nanoindentation, nanolithography and Nanomanipulation.		
	<b>c</b> . Specimen Stage:		
	i. Motorized sample translation stage with about 125 mm travel in the X and Y directions		
	<ul> <li>Step resolution ~2μm and at least 8μm repeatability for any directions.</li> </ul>		
	iii. Z translation stage: > 25 mm motorized and at least 5 mm on servo control		
	iv. The sample stage should able to rotate about its centroid		
	v. Sample holders of ~150 mm diameter with vacuum		

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		chuck to hold semiconductor wafers, hard drive etc. Magnetic holders for smaller samples up to ~15 mm. Sample holder should compatible with ~10 mm thicker samples.	
	vi.	Compatible with sample weight: up to 500 gm.	
D.	Scar	nners:	
	i.	XY scan range: 90 μm×90 μm (closed loop)	
	ii.	Z range: 10 $\mu$ m, large vertical range ~30 $\mu$ m should also be quoted, Z noise: < 0.05 nm and sensor non-linearity < 0.05%	
	iii.	Imaging bandwidth >600 Hz	
	iv.	For small scans XY scanner: 10 $\mu$ m×10 $\mu$ m (closed loop), Z range: 2 $\mu$ m, Z noise: < 0.03 nm and sensor non-linearity < 0.05%, XY non-linearity <1% (in case of single scanner the scanner used must be compatible with these specifications for small scan size)	
	V.	Standard scan modes in air and fluid should be available	
	vi.	All three axes should have closed feedback and independent nano positioning sensors	
	vii.	Overall drift of the system should be < 0.2 nm/min	
	viii.	Scan heads must be calibrated with NIST standard.	
	ix.	The AFM must be capable of scanning atomic resolution images on atomic lattice structures such <u>as Mica.</u> The AFM should be capable of scanning <300 nm scans in closed loop operation and maintain positional accuracy of <0.15 nm.	
E.	. Micr	oscope optics:	
	i.	Sample illumination: Integrated color camera (minimum 5 MP) with software controlled power adjustable white LED light source	
	ii.	Motorized zoom and focus	
	iii. iv.	Field of view variable from min 1 mm to 200 $\mu$ m	
	V.	Optical resolution: better than 2µm Camera software should be within AFM software.	
F.	Elec	tronics and controller:	
	i. 	High performance DSP based electronics	
	ii. 	Data acquisition sampling rate ~50 MH	
	iii.	All the ADC and DAC must be $\geq$ 16 bits	
	iv.	Digital Q control of the cantilevers quality factor, should	

	allow simultaneous collection of up to 8 data channels simultaneously, should provides thermal tuning of cantilevers to 2MHz in air or fluid to determine cantilever's resonant frequency and spring constant ( <b>demonstrable</b> )	
	<ul> <li>Should provides 3 user accessible lock-in amplifiers and should be capable of applying up to10V bias to the AFM tip or sample</li> </ul>	
	vi. It must provides real time adjustment to all scanning parameters – scan rate, scan size, scan offset, gains and others	
	vii. Should support use of micro-actuated cantilevers for fast scanning (up to 10Hz)	
	<ul> <li>viii. Fast, single cable USB based computer-to-controller communication should be available, electrical noise: &lt; 1 pA, Bandwidth: ~500 kHz</li> </ul>	
	ix. Access to all major signals on BNC connectors through either controller front panel or by a break-out box	
	x. Image resolution must be greater than $5k \times 5k$ .	
	. Software and computer:	
	i. Fully functional software for data acquisition and data	
	<ul> <li>analysis for operating system Windows XP or Vista</li> <li>ii. Thumbnail view should be available to allow searching, sorting and viewing AFM-specific data files to work with other software</li> </ul>	
	iii. Scientific publication-quality graphing and layout capabilities and movie making facilities should be available within the control and analysis software environment	
	<ul> <li>iv. Generation, display, and visualization of 3D images in real-time (during scan as well as off-line processing).</li> <li>v. Computer: Windows XP or vista with dual flat panel Monitors (21 inch or larger), 320 GB HDD, CD/ DVD writer, USB ports (8), should be able to export files to the clipboard or save as JPEG, PNG, BMP, TIFF etc.</li> </ul>	
н.	. Vibration isolation:	
	i. A compatible active/passive vibration isolation system for atomic scale imaging.	
	<ul> <li>The system should include acoustic enclosure which should provide acoustic noise isolation better than 20 dB.</li> </ul>	
I.	Sample heating/cooling option: The sample heating/cooling option (-25 °C to 250 °C) with 0.1 °C temperature stabilization.	

	J. Power: 220-250 Vac 50 Hz
2	Other desirable operating mode:
	<ul> <li>a) Liquid cell imaging:</li> <li>i) Disposable/easily cleanable small volume fluid/gas cell</li> </ul>
	<ul><li>ii) A sealed environmental chamber with multiple ports for fluid/gas exchange.</li></ul>
	b) Nanoindentation and nanomechanical measurements:
	i) Both cantilever based nanoindentation and full-fledged nanoindentation capabilities using standard indenters like Berkovitch, Cube corner and spherical etc. should be quoted
	<ul> <li>ii) No drift problem</li> <li>iii) Diamond coated tip based Nano Indentation with</li> <li>necessary hardware and software should be provided.</li> </ul>
	c) Nanolithography and nanomanipulation:
	<ul> <li>i) The cantilever should be able to control lithography and manipulation applications. Capabilities should be preferably built-in without the need for extra hardware or software</li> </ul>
	ii) Should able to generate patterns with freehand curves
	and possibility of patterns import should be present
	iii) The cantilever amplitude, deflection, and voltage must be controllable and modulated during lithography.
	d) Conducting AFM for highly resistive materials:
	<ul> <li>Apart from the normal conducting mode capability, it should be able to measure current for highly resistive samples with a resolution of approximately 50 femto-amps, having maximum noise level of 100 femto-amps.</li> </ul>

Calibration samples for all the different operating modes as given in S. No. 1 above must be provided. A set of spring constant calibrated cantilevers for force-distance microscopy and tip radius calibration gratings should also be provided. **The atomic scale imaging of mica in ambient condition should be demonstrable.** All the necessary installation and training must be provided by the vendor.

**Users list:** Vendors should also specify the user list for the said item in India as well as abroad.

**Warranty:** (**Required**) On-site comprehensive including part replacement specify for 1 year and 2 years. This should be clearly shown in the technical as well as financial bid.

## Terms and conditions covering submission of quotations

1. DELIVERY:	The rate must be C.I.F. IIT Delhi (Air Freight),
	Delhi Airport
2. TERMS OF PAYMENT:	Letter of credit
3. VALIDITY OF QUOTATIONS	three months or more
4. CORRESPONDENCE:	No correspondence regarding acceptance /rejection of quotation will be entertained.
5. SUBMISSION OF QUOTATIC	<b>DNS:</b> <u>Separate quotations should be submitted</u> for technical bid and commercial bid in two separate and clearly marked envelopes.
6. DISCOUNTS/REBATES:	Special discounts/rebate wherever admissible
	keeping in the view that supplies are being made
	for an Educational institute may be indicated in the
	offer.
7. DIRECTOR'S RIGHT:	Director, IIT Delhi reserves the right of acceptance or rejection of any or all quotations without assigning any reason.

Please specify terms and conditions. The quotations must have a validity of 3 months. Sealed quotations (<u>separate technical and financial</u>) may be send to the following address.

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